

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S3	1	"20010053489".did.	US-PGPUB; USPAT	ADJ	ON	2008/12/18 17:33
S8	1	(blur\$3 intensity basic)	US-PGPUB; USPAT	ADJ	ON	2008/12/21 12:43
S9	1	"5745799".pn.	US-PGPUB; USPAT	ADJ	ON	2008/12/21 12:45
S10	5	"499271".ap.	US-PGPUB; USPAT	ADJ	ON	2008/12/21 12:55
S1	6	"598035".ap.	US-PGPUB; USPAT	ADJ	ON	2008/12/18 17:31
S34	14	blurred point spread function	US-PGPUB; USPAT	ADJ	ON	2008/12/22 09:23
S35	16	blurred point spread function	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/12/22 09:24
S32	19	(first exposure dose) NEAR (second exposure dose)	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:53
S6	42	(blur\$3 OR aberration) point spread function	US-PGPUB; USPAT	ADJ	ON	2008/12/21 12:09
S33	82	((first exposure) NEAR (second exposure)) AND ((photoresist OR resist) layer)	US-PGPUB; USPAT	ADJ	ON	2008/12/21 14:01
S27	310	S18 AND "382".clas.	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:33
S36	353	382/255.ccls.	US-PGPUB; USPAT	ADJ	ON	2008/12/22 10:39
S31	486	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion AND illumination	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:36
S39	777	382/300.ccls.	US-PGPUB; USPAT	ADJ	ON	2008/12/22 11:37
S38	832	382/299.ccls.	US-PGPUB; USPAT	ADJ	ON	2008/12/22 11:23

S30	4895	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:36
S25	21381	S22 AND @py< "2006" AND @ay> "2000"	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:32
S26	21381	S18 AND @py< "2006" AND @ay> "2000"	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:33
S29	22293	((photoresist OR resist) layer) OR (PR) AND solubility	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:35
S23	44902	S22 AND @py< "2006"	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:32
S24	44902	S22 AND @py< "2006" AND @ad> "2000"	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:32
S17	65402	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion AND illumination AND activated AND blur AND lithiography	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:26
S18	65402	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion AND illumination AND activated AND image blur AND lithiography	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:27
S21	65402	((photoresist OR resist) layer) OR (PR) AND photo acid generator AND "382". clas.	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:29
S22	65402	((photoresist OR resist) layer) OR (PR) AND photo acid generator AND (activated by illumination)	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:30
S16	65403	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion AND illumination AND activated AND blur	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:25
S20	65470	((photoresist OR resist) layer) OR (PR) AND photo acid generator	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:28

S19	65505	((photoresist OR resist) layer) OR (PR) AND photo acid	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:28
S15	65589	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion AND illumination AND activated	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:25
S14	65660	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion AND illumination	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:25
S13	68471	((photoresist OR resist) layer) OR (PR) AND solubility AND diffusion	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:25
S12	81878	((photoresist OR resist) layer) OR (PR) AND solubility	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:24
S11	163831	((photoresist OR resist) layer) OR (PR)	US-PGPUB; USPAT	ADJ	ON	2008/12/21 13:24

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